



Form 1449 (Modified)	Atty Docket No. CISC831
<b>Information Disclosure Statement By Applicant</b>	Application No.: 10/630,582
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	Group 1326
	Filing Date July 29, 2003
	Mailing Date July 7, 2004
(Use Several Sheets if Necessary)	

#### U.S. Patent Documents

Examiner Initial	No.	Patent No.	Date	Patentee	Class	Sub- Class	Filing Date
JR	AA	6,433,921 B1	08/13/02	Wu et al.	359	334	02/15/01
JR	AB	6,587,260 B2	07/01/03	Kikuchi et al.	359	334	08/24/01

#### Foreign Patent or Published Foreign Patent Application

Examiner Initial	No.	Document No.	Publication Date	Country or Patent Office	Class	Sub- class	Translation	
							Yes	No
JR	AC	2001197006A	07/19/01	JP			Abst	
JR	AD	03/034111 A2	04/24/03	WO			Yes	

#### Other Documents

Examiner Initial	No.	Author, Title, Date, Place (e.g. Journal) of Publication
JR	AE	Kaneko, Akimasa et al., "Design and Applications of Silica-Based Planar Lightwave Circuits," IEEE Journal of Selected Topics in Quantum Electronics, Vol. 5, No. 5, September/October 1999, pp. 1227-1236.
JR	AF	Ramaswami, R. et al. "Optical Networks: A Practical Perspective," pp. 112-115, 1998.
JR	AG	Tomkos, I. et al., "Ultra-Long-Haul DWDM Network with 320x320 Wavelength-Port 'Broadcast & Select' OXCs," European Conference on Optical Communication, September 2002, Copenhagen, Denmark, post-deadline paper PD2.1.
JR	AH	Tomkos, I. et al., "80x10.7 Gb/s Ultra-Long-Haul (4200+ km) DWDM Network with Reconfigurable 'Broadcast & Select' OADMs," Optical Fiber Communication Conference 2002, post-deadline paper FC1.
JR	AI	Vasilyev, M. et al., "Transparent Ultra-Long-Haul DWDM Networks with 'Broadcast & Select' OADM/OXC Architecture," Journal of Lightwave Technology, 2003, 20, 2661.
JR	AJ	Vasilyev, M. et al., "Broadcast & Select OADM in 80x10.7 Gb/s Ultra-Long-Haul Network," IEEE Photon. Technol. Lett., 2003, 15, 332.
Examiner /Jerry Rahll/		Date Considered 05/10/2006

Examiner: Initial citation considered. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.